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(11)

EP 0 702 270 A3

(12)

EUROPEAN PATENT APPLICATION

(88) Date of publication A3:
29.10.1997 Bulletin 1997/44

(51) Int Cl.⁶: **G03F 7/037**

(43) Date of publication A2:
20.03.1996 Bulletin 1996/12

(21) Application number: **95306417.7**

(22) Date of filing: **13.09.1995**

(84) Designated Contracting States:
DE GB

(30) Priority: **13.09.1994 JP 247109/94**
26.09.1994 JP 256222/94

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(54) **Photosensitive polyimide resin composition**

(57) Provided are photosensitive resin compositions comprising a polyamic compound having, at each terminal thereof, a specific actinic ray-sensitive functional group which has substituent groups each having a photopolymerizable carbon-carbon double bond, a

photosensitive auxiliary having a photopolymerizable functional group and a solvent. The photosensitive resin compositions of the invention are excellent in resist properties such as sensitivity and good in storage stability and can provide a film small in residual stress.

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EUROPEAN SEARCH REPORT

Application Number
EP 95 30 6417

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.6)
A	EP 0 571 899 A (BASF LACKE + FARBEN AKTIENGESELLSCHAFT) * page 10 - page 11; claim 1 * ---	1-20	G03F7/037
A	DATABASE WPI Section Ch, Week 9318 Derwent Publications Ltd., London, GB; Class A26, AN 93-149266 XP002038593 & JP 05 086 154 A (TOSHIBA KK) , 6 April 1993 * abstract * ---	1-20	
A	US 4 568 601 A (C.J. ARAPS ET AL.) * columns 5 and 6, POLY(AMIC ACID) * ---	1-20	
A,D	EP 0 430 221 A (SUMITOMO BAKELITE COMPANY LIMITED) * claim 2 * -----	1-20	
The present search report has been drawn up for all claims			TECHNICAL FIELDS SEARCHED (Int.Cl.6)
			G03F
Place of search		Date of completion of the search	Examiner
THE HAGUE		22 August 1997	J.-M. DUPART
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document			

EPO FORM 1503 03.82 (P04C01)